

CMOS SENSOR WITH OVER-SATURATION ABATEMENT

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FIELD OF THE INVENTION

[0001] This invention generally relates to light sensing circuitry. The invention more specifically relates to circuits for CMOS based image-sensing circuits such as may typically be found in digital electronic cameras.

BACKGROUND OF THE INVENTION

[0002] Electronic digital cameras are superseding traditional cameras which rely upon chemical processing. As with other consumer oriented electronic products there is great pressure to reduce costs. There is also the need for low cost solid state image sensors to complement computers and communication devices and for practicable video conferencing and so on. The image input device is central to such applications. CMOS image sensors have proven themselves to be superior image input devices for low power mobile operations. CMOS image sensors may also have other applications. An important advantage of CMOS image sensors (or imagers) is that imager and signal processing circuits can easily be integrated on a single semiconductor chip. This brings into prospect single-chip camera systems. Charge coupled devices (CCDs) are used as an alternative to CMOS imagers, however, the latter may be cheaper to fabricate for a given level of performance and capacity. CMOS fabs such as may be used to build the invention are well known in the art. Typically, image sensors produce digitized raster-like arrays of electronic luminance signals corresponding to and responsive to the incident light that makes up an image.

[0003] The image sensor quality produced by CMOS image sensors has been improving in recent years to the point that CMOS image sensor performance begins to rival CCD image sensor performance. Thus, CMOS image sensors have begun to penetrate the DSC (digital still camera) marketplace. In order to ensure good image quality, CMOS image sensors may use CDS (correlated double sampling) circuits to remove FPN (fixed pattern noise). CDS is well

known in the art. The use of CDS circuits has introduced a problem in that pictures of extremely bright lights or reflections from shiny surfaces may be imaged poorly. In these conditions, a spurious dark central area may appear in the middle of a very bright area. This phenomenon is sometimes termed image inversion. A method and image sensor with over-saturation detection and image inversion correction circuitry that solves the subject problem is described.

SUMMARY

[0004] According to an aspect of the invention, a method for image sensing is disclosed. The method may comprise producing, from a photo detector, a plurality of detected electronic signals; amplifying them, with a column buffer amplifier, to produce a plurality of amplified signals; sampling some of the amplified signals, with a correlated double sampler, and clamping signals in response to over-saturation conditions. Thus, image inversion is at least partially abated.

[0005] According to a further aspect of the invention, a method for enhancing a video image is disclosed. The method may comprise sampling image signals with a correlated double sampler and clamping signals during a reset phase of the correlated double sampler.

[0006] According to a further aspect of the invention, a circuit is disclosed. The circuit may comprise an image sensor array comprising a clamp circuit, a column buffer amplifier, and a correlated double sampling circuit.

[0007] According to a further aspect of the invention, a method for processing a signal is disclosed. The method may comprise producing a plurality of output luminance signals responsive to an incident light, generating a first sample of one of the luminance signals at a first time and a second sample of the respective luminance signal at a second time, producing a threshold passed signal output responsive to a condition of over-saturation by the incident light, and clamping the respective luminance signal sample during the first time responsive to the threshold passed signal.

[0008] According to a still further aspect of the invention, a circuit for providing a signal is disclosed. The circuit may include a plurality of pixel cells, a correlated double sampler, a threshold detection circuit having a threshold passed signal output responsive to a condition of

one of the pixel cells of being over-saturated by the incident light; and a clamp circuit wherein the clamp circuit clamps a respective luminance signal.

[0009] According to a still further aspect of the invention, a circuit for providing a signal is disclosed. The circuit may include a means for producing a plurality of output luminance signals responsive to an incident light, a means for generating a first sample of one of the luminance signals at a first time and a second sample of the respective luminance signal at a second time, a means for producing a threshold passed signal output responsive to a condition of over-saturation by the incident light, and a means for clamping the respective luminance signal sample during the first time responsive to the threshold passed signal.

BRIEF DESCRIPTION OF THE DRAWINGS

[0010] Figure 1 is a block diagram of image sensor circuitry according to an embodiment of the invention.

[0011] Figure 2 shows temporal waveforms of some signals according to an embodiment of the invention.

[0012] Figure 3 shows further temporal waveforms of COL-OUT signals according to an embodiment of the invention.

[0013] Figure 4 shows more temporal waveforms according to an embodiment of the invention.

[0014] Figure 5 shows in part schematic, part block diagram, pixel cell and per-column circuits according to an embodiment of the invention.

[0015] Figure 6 shows in part schematic, part block diagram, pixel cell and per-column circuits according to an alternative embodiment of the invention.

[0016] Figure 7 shows in part schematic, part block diagram, pixel cell and per-column circuits according to another alternative embodiment of the invention.

[0017] Figure 8 shows in part schematic, part block diagram, an exemplary clamp circuit according to an embodiment of the invention.

[0018] Figures 9A, 9B, 9C and 9D show in part schematic, part block diagram, an exemplary clamp circuit according to further exemplary embodiments of the invention.

[0019] Figure 10 is a block diagram of image sensor circuitry according to an alternative embodiment of the invention.

[0020] Figure 11 is a block diagram of image sensor circuitry according to a further alternative embodiment of the invention.

[0021] For convenience in description, identical components have been given the same reference numbers in the various drawings.

DETAILED DESCRIPTION

[0022] In the following description, for purposes of clarity and conciseness of the description, not all of the numerous components shown in the schematic are described. The numerous components are shown in the drawings to provide a person of ordinary skill in the art a thorough enabling disclosure of the present invention. The operation of many of the components would be understood and apparent to one skilled in the art.

[0023] Figure 1 is a block diagram of image sensor circuitry 101 according to an embodiment of the invention. The image sensor circuitry 101 could be used to produce still video images or moving video images such as motion pictures. Pixel cell circuit 110 provides a pixel signal 119 to per-column circuit 120. In one embodiment, pixel cell circuit receives optical input (not shown) and produces pixel signal 119 in response to the optical input, a reset signal 111 and a rowselect signal 112. Pixel signal 119 may be comprised of multiple signals conveyed by multiple conductors within the general scope of the invention. Column-buffer amplifier 140 produces output COL-OUT signal 129 and exchanges a signal 159 with clamp circuit 150. CDS circuit 130 performs correlated doubling sampling to produce an output signal CDS-OUT 139 in response to COL-OUT signal 129, Sample signal 113 and Sample reset 114. In this embodiment, per-column circuit 120 includes column-buffer amplifier 140 and clamp circuit 150.

[0024] Still referring to Figure 1, an complete image sensor may be embodied using a large number of pixel cells arranged in a matrix having rows and columns. The rows and columns typically map onto horizontal and vertical directions, or vice versa, in the picture being imaged. Thus pixel cells are embodied as many instances and the cost per pixel cell must be held down. As the name suggests, the per-column circuit may be embodied on the basis of one instance of

this circuit per column of pixel cells. In alternative designs there may be a small number, rather than one per-column circuit per column of pixel cells. The clamp circuit 150 and the CDS circuit 130 are each associated one to one with a per-column circuit 120, hence they are all three equal in number in a typical embodiment.

[0025] Figure 2 shows temporal waveforms of some signals according to an embodiment of the invention. Trace 229 represents the COL-OUT signal 129. Three possible waveforms are shown, 229A, 229B and 229C, corresponding to incident light conditions of dark, moderate, and saturated (but not over-saturated). Saturated light conditions occur when the incident light is just so bright that the corresponding waveform trace reaches the end of its range. Over-saturated light conditions are conditions wherein the incident light is brighter than saturated conditions. Contrast may be lost or image inversion may occur when light conditions become over-saturated. Trace 211 represents the Reset Signal 111. The Reset Signal 111 is used to establish the black reference level for the picture. When Rowselect signal 212 goes active (high in this exemplary embodiment), COL-OUT 229 is pulled high. A little later, when Reset 211 is released, COL-OUT 229 drops rapidly a fixed amount according to a charge injection phenomenon explained below. Thereafter, COL-OUT 229 falls relatively slowly along one of the exemplary lines 229A, 229B or 229C or some other intermediate line responsive to the incident light level. Then the cycle starts again.

[0026] Referring together to Figures 1 and 2, signal 212 represents the row select signal 112. Pixel cells are arranged in rows and columns and once per waveform cycle, a particular row of cells are activated with the row select signal 212. Thus only one active pixel cell is associated with each per-column circuit at any time. In Figure 2, row select 212 is shown active during the complete waveform cycle shown but is inactive in the second cycle (which is shown only in part). Consequently the COL-OUT signal path 229X is due to another pixel cell and not the one for which the row select signal 212 is shown. Signal 214 represents the "Sample Reset" signal, this signal is used by the CDS circuit 130 to strobe in a COL-OUT signal 229 datum value 250. Signal 213 represents the "Sample signal" signal 113, this signal is used by the CDS circuit 130 to strobe in a COL-OUT signal 229 light dependent value, for example, 260A, 260B or 260C according to the light level. The CDS circuit differences the values 250 from 260A (or 260B or 260C or some intermediate value) to produce the CDS-OUT signal (not shown in Figure 2).

[0027] Figure 3 shows further temporal waveforms of COL-OUT signals 229J and 229K according to an embodiment of the invention. Referring together to Figures 1 and 3, trace 229J shows the COL-OUT signal for a slightly over-saturated pixel. The over-saturation causes the trace to stop falling as it reaches a limit prior to having a sample 260J taken in response to a "Sample signal" signal (not shown in Figure 3). In the case of trace 229J, the reset datum sample 250J is formed in a manner similar to unsaturated conditions (as in Figure 2) and the CDS circuit 130 will produce a valid value for the CDS-OUT signal.

[0028] Trace 229K represents a COL-OUT signal for an over-saturated pixel. After reset is released the curve falls rapidly to reference level 310 due to the action of charge injection as is explained below. Then the trace continues to fall rapidly due to the heavy over-saturation of the photo-sensitive detector. As the COL-OUT voltage passes threshold level 320, the clamp circuit 150 detects this condition and acts to pull the voltage high and hold it high until after the "Sample reset" datum sample 250K has been taken by the CDS circuit 130. Thereafter the curve falls rapidly resulting in a "Sample signal" value 260K at the same (saturated) level as sample 260J. The action of the clamp circuit prevents a bad "Sample reset" datum sample from being taken, such as the value shown as 250Z, which would result in an erroneous CDS-OUT value from the CDS circuit 130. This type of erroneous CDS-OUT may manifest itself as image inversion in a composed image. For example the sun may appear to have a dark disk at its center. A problem overcome by the invention is that in previously developed implementations, values for the datum sample may be unrepresentative of the reset level due to the signal falling too quickly, i.e., with excessive slewing. Other means of detecting the signal level slewing and falling too quickly are feasible within the general scope of the invention.

[0029] Figure 4 shows more temporal waveforms according to an embodiment of the invention. Referring to both Figure 1 and Figure 4, trace 451 represent the Clamp Enable signal 151 (Figure 1). Part of a COL-OUT signal trace is shown as 229K, the trace corresponding to a heavily over-saturated pixel condition. When the Clamp Enable 151 signal goes high (shown as 401), the clamp circuit begins to compare the COL-OUT signal 229K with the voltage level of the Vtrip 152 signal, shown as 320. When the COL-OUT signal 229K goes below the Vtrip level 320 (this point is shown as 403) and provided Clamp Enable 151 is asserted, the clamp circuit 150 clamps the COL-OUT signal 229 to the Vtrip level 320. This action enables a good measurement 250K to be taken by the CDS circuit 130 at the Vtrip level 320. For good performance the Vtrip level should be set as close as possible to the reference level without

suffering false trips due to noise or other causes. When the Clamp Enable 151 signal is no longer asserted (shown as 402), then the clamp circuit 150 releases the COL-OUT signal 229K which then begin a rapid descent towards saturation. Thus, the clamp circuit 150 acts to prevent a bad measurement such as the hypothetical value 250Z.

[0030] Figure 5 shows in part schematic, part block diagram, exemplary pixel cell and per-column circuits according to an embodiment of the invention. Each pixel cell 110 may include a light sensitive photo detector 521 providing a photo-charge responsive to incident light. Photo detectors may be embodied in various ways such as photo diodes or photo gates. Each pixel cell 110 further may include a first, second, and third transistors 522, 523, and 524 to provide and output indicative of the intensity of the incident light. Operation of the exemplary pixel cell circuit 110 depicted in Figure 5 is apparent to one of ordinary skill in the art.

[0031] Still referring to Figure 5, the per-column circuit 120 may include a current source 531. In the absence of over-saturation conditions, the clamp circuit 150 has no effect upon the COL-OUT signal 129. In a strong over-saturation condition, a clamp circuit 150 will trip at the pre-determined threshold voltage V_{trip} 152, during the clamp enabled period which is determined by the "Clamp Enable" signal 151. After clamp circuit 150 has tripped and while the "Clamp Enable" signal 151 remains asserted, the clamp circuit 150 acts to limit the COL-OUT signal voltage. Once the voltage level from the source of transistor 524 falls below the clamp circuit 150 trip voltage V_{trip} 152, the clamp circuit 150 activates and limits the COL-OUT 129 signal voltage.

[0032] Figure 6 shows in part schematic, part block diagram, pixel cell, and per-column circuits according to an alternative exemplary embodiment of the invention that utilizes a differential feedback amplifier. Pixel cell 110 and per-column circuit 120 are shown. The circuit comprises photo-detector 521, transistors 622, 623, 624, and 625, current source 631, differential feedback amplifier 640 and clamp circuit 150, having input port IN 620. Differential feedback amplifier is used as a column buffer amplifier in the exemplary embodiment. Other forms of column buffer amplifier may be used within the general scope of the invention, for example, a single-ended amplifier and/or a source follower could be used to produce amplified signals. As a further example, portions of the column buffer amplifier functions may be distributed among pixel cells 110.

[0033] Figure 7 shows in part schematic, part block diagram, pixel cell, and per-column circuits, according to another exemplary alternative embodiment of the invention that utilizes a single-ended feedback amplifier 740.

[0034] Figure 8 shows in part schematic, part block diagram, an exemplary clamp circuit 150 according to an embodiment of the invention. Amplifier 810 and feedback circuit 820 form a feedback loop that clamps the IN signal to V_{trip} when the clamp signal is active.

[0035] Figures 9A, 9B, 9C, and 9D show in part schematic, part block diagram, an exemplary clamp circuit according to further exemplary embodiments of the invention. In Figures 9A and 9B, the clamp enable signal 151 has two functions. Firstly the clamp enable signal enables the clamp circuit. Secondly the clamp enable signal establishes the level of V_{trip} , referenced to VRD. In these cases the clamp enable signal is a threshold-passed signal, that is, it becomes asserted when the IN signal 620 passes a threshold that corresponds to detection of an over-saturation condition in a pixel cell. In Figure 9C a separate V_{trip} is used in conjunction with a gain amplifier to more accurately clamp the IN signal to the V_{trip} level. In Figure 9C, port V_{BN} receives as bias voltage for bias current control. In Figure 9D, the signal Not-Clamp-Enable 951 is a negative logic version of the signal clamp enable 151 in the earlier figures.

[0036] Figure 10 is a block diagram of image sensor circuitry 1001 according to an alternative embodiment of the invention. As contrasted with the block diagram of figure 1, clamp circuit 1050 monitors output from the column buffer amplifier 140 but its clamp action is to impress a voltage Sat Enable 1095 upon the MUX (multiplexer) 1099 during conditions of over saturation. The MUX then selects between two input signals, one of which goes forward as a signal 1090 to an A/D (analog to digital converter – not shown in figure 10). The MUX receives the CDS-OUT signal 139 and a V_{sat} voltage corresponding to saturated light conditions from the V_{sat} voltage generator 1098. It is obvious to persons of ordinary skill in the art to provide a revised clamp circuit and a voltage generator. Similar alternative and equivalent embodiments within the general scope of the invention will be apparent to persons of ordinary skill in the art.

[0037] One such similar or equivalent embodiment of the invention is shown in figure 11 which shows a block diagram of image sensor circuitry 1101 according to an alternative embodiment of the invention. As contrasted with the block diagram of figure 10, an A/D 1110 is shown and a digital MUX 1190. Sat Enable 1095 controls the digital MUX 1190 which selects between

multi-bit signals from the A/D 1110 and from a digital value reference Dsat 1180. Such components and their usage are well known to persons of ordinary skill in the art.

[0038] Embodiments of the invention as described herein have significant advantages over previously developed implementations. For example, previously developed embodiments of image sensors fail to adequately abate image inversion due to the reaction of some CDS circuits to over-saturation. Also with appropriate adjustments as are well-known in the art P-well or N-well common industry processes may be used. P-channel devices and n-channel devices may be interchanged with appropriate source-drain and polarity transpositions as is well known in the art. Many other embodiments are feasible within the general scope of the invention and will be apparent to those of ordinary skill in the relevant arts. Many other means of detecting the signal level slewing and falling too quickly are feasible within the general scope of the invention. For example, a differentiator coupled to a high pass filter could be used to detect the high frequency spike and hence spectral content associated with a very fast slew over a large potential difference.

[0039] The embodiments described above are exemplary rather than limiting and the bounds of the invention should be determined from the claims.